

Name:				Date:			Sample ID:	
P _{loadlock} :				P _{chamber} :			P _{chamber @ T} :	
Presputtering								
Target	T	Gas	Gas flow	gas pressure	Rotate	Current	Voltage	Duration
1.								
2.								
3.								
4.								
Sputtering								
Target	T	Gas	Gas flow	gas pressure	Rotate	Current	Voltage	Duration
1.								
2.								
3.								
4.								
Post:				Other:				

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